

Notice of References Cited

Application/Control No.

09/653,281

Applicant(s)/Patent Under

Reexamination

BEAMAN ET AL.

Examiner

Richard A. Booth

Art Unit

2812

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U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-			
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	C	US-			
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FOREIGN PATENT DOCUMENTS

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NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages
	U	Hoff et al., "Atomic Oxygen and the thermal oxidation of silicon", Applied Physics Letters 52 (15), April 1988, pages 1264-1265.
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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)

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